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# *In situ* growth of SeO<sub>x</sub> films on the surface of Ni–Fe–selenide nanosheets as highly active and stable electrocatalysts for the oxygen evolution reaction†

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Reasonable design, extremely low-cost, high efficiency and high durability oxygen evolution reaction (OER) catalysts are essentially required to promote the practical large-scale applications of electrocatalytic water splitting for the efficient production of hydrogen. Herein, a rapid, facile, green and controllable electrochemical deposition method is reported for the growth of SeO<sub>x</sub> films on the surface of Ni–Fe–selenide nanosheets (SeO<sub>x</sub>/FeNi<sub>x</sub>Se) through the hydrogen evolution reaction (HER) cycle process, which are used as highly active and stable electrocatalysts for the OER. The obtained SeO<sub>x</sub>/FeNi<sub>x</sub>Se heterojunction nanosheets have interconnected heterostructures, which play a vital role in boosting the catalytic performance by offering rich active sites and convenient pathways for rapid electron transport. Detailed spectroscopic and DFT investigations disclose that the strong electron interaction between FeNi<sub>x</sub>Se and SeO<sub>x</sub> could reduce the surface charge-transfer-resistance, and improve the electrocatalytic properties and the structural stability of the electrode. The optimized SeO<sub>x</sub>/FeNi<sub>x</sub>Se (CM7-FeNi<sub>x</sub>Se) catalyst exhibits superior OER activities to the commercial Ir and most of the reported Ni-based selenide catalysts with a small overpotential of 285 mV to achieve a current density of 200 mA cm<sup>-2</sup> in 1.0 M KOH. This finding provides a new ultrathin oxide layer preparation strategy to boost the OER catalytic activity.

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## Introduction

Electrocatalytic water splitting is one of the most promising strategies for the efficient production of hydrogen with environmental benignity and low-cost consumption.<sup>1</sup> As a pivotal half reaction in water-splitting, the anodic oxygen evolution reaction (OER) is more complex than the cathodic hydrogen evolution reaction (HER) due to the four electron transfer processes with high overpotential, which greatly hinders its large-scale industrial application.<sup>2–5</sup> Although noble metal-based Ir or RuO<sub>2</sub> catalysts can significantly reduce the overpotential and accelerate the kinetics of the OER, the high cost impedes their extensive applications.<sup>6–10</sup> Thus, over the past few years, many earth-abundant materials with lower cost have been developed to improve the reaction efficiency of the OER, such as transition metal-based selenide,<sup>11,12</sup> nitride,<sup>13–15</sup> sulfide,<sup>16,17</sup> phosphide,<sup>18,19</sup> and oxide<sup>20–22</sup> supported non-metallic carbon compound electrocatalysts.<sup>23,24</sup>

Among them, transition metal-based selenides have been reported as prospective OER catalysts due to their intrinsically metallic conductive properties which would efficiently enhance their electron transfer capability during the catalytic reaction process.<sup>25,26</sup> However, further research in recent years has

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shown that transition metal-based selenides will transform into metal oxides and/or (oxy)hydroxides during the catalytic process under alkaline conditions, thus showing low stability under alkaline conditions, which negate the catalytic ability of transition metal-based selenides themselves. As a result, the oxide species formed *in situ* during catalytic reactions are almost invariably identified as the real active species.<sup>27–29</sup> Although such a change is conducive to the improvement of catalytic performance, the content of oxides is uncontrollable. On the one hand, too much oxides will reduce the conductivity of the materials; on the other hand, phase changes during the cycling process will affect the stability of the materials, which may lead to structural collapse. It has been demonstrated that the catalytic reaction is dependent on the electrochemically active sites on the surface of materials. Therefore, for the metal oxides converted from selenides in the catalytic reaction process, the surface oxides are key to improving the catalytic performance of the materials, while the internal oxides do not play a major role in the catalytic reaction due to their intrinsic poor conductivity, which is not conducive to electron conduction. Based on the above-mentioned analysis, we propose the formation of a heterostructure by growing an ultrathin metal oxide layer on selenides to improve the catalytic activity without affecting the conductivity of materials. Various different protocols are available for growing oxide films over substrates. The traditional preparation methods, such as the hydrothermal method and high temperature calcination method, have low controllability, which is quite challenging to control the content and thickness of the produced oxide layer. Several recent studies have shown that a thin layer is formed on the surface of the metal phosphates during their HER performance testing.<sup>30</sup> Inspired by this, in this work, selenides were used as the substrate and precursor. The electrochemical deposition process was used as a means for the *in situ* growth of a layer of ultra-thin oxides on the surface of selenides to obtain oxide/selenide heterojunction structures.

With this in mind, herein, three-dimensional (3D) nanosheets with interconnected  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  heterostructures are fabricated by the electrochemical deposition process through the hydrogen evolution reaction (HER) cycle process using  $\text{FeNi}_x\text{Se}$  as the precursor and NiFe foam as the conductive substrate. A single electrochemical deposition process takes only 90 s for completion. Attractively, this electrochemical deposition process effectively avoids the use of any additional solvents and reactants, and a thin layer of  $\text{SeO}_x$  with optimized thickness can be obtained by performing the electrochemical deposition process 7 times. Thus, it is a rapid, facile, green and controllable preparation method. The optimized ultra-thin  $\text{SeO}_x$  film (~8 nm) heterogenized with  $\text{FeNi}_x\text{Se}$  nanosheets could considerably enhance the active sites and increase the OER catalytic activity. DFT calculation and spectroscopy analysis have confirmed that the synergistic effect between inner  $\text{FeNi}_x\text{Se}$  and surface  $\text{SeO}_x$  can reduce the adsorption energy with an oxygenated intermediate and improve the reaction kinetics of the OER. Moreover, the thin layer of  $\text{SeO}_x$  on the surface can prevent continued oxidation of  $\text{FeNi}_x\text{Se}$  in the subsequent OER test, which improves the structural stability and electrochemical

properties. The obtained 3D nanosheets with interconnected heterostructures could offer a large interfacial contact area with electrolytes and a convenient pathway for rapid electron transport. The optimized  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  (CM7- $\text{FeNi}_x\text{Se}$ ) catalyst exhibits superior OER activities to the commercial Ir and most of the reported Ni-based selenide catalysts with a small overpotential of 285 mV to achieve 200  $\text{mA cm}^{-2}$  current density in 1.0 M KOH.

## Experimental section

### Synthesis of $\text{FeNi}_x\text{Se}$ nanosheet arrays with interconnected structures

$\text{FeNi}_x\text{Se}$  nanosheet arrays were synthesized by a facile solvothermal reaction and *in situ* selenization process. A piece of NiFe foam (3 cm × 3 cm) was cleaned by sonicating it in 2.0 M HCl and ethanol for 10 min, respectively. 5 mmol nickel nitrate hexahydrate and 40 mmol urea were added into 70 mL distilled water under stirring for 30 min to form a uniform solution. Then, the above solution and the clean NiFe foam were transferred to a 100 mL Teflon-lined stainless steel autoclave and heated to 135 °C for 12 h. After being cooled to room temperature, FeNi layered double hydroxide (FeNi-LDH) grown on the surface of the NiFe foam was obtained by washing with deionized water and drying naturally. For further selenization, 5 mmol Se powder was added into a 50 mL solution containing 5 mL hydrazine hydrate and 45 mL deionized water under stirring for 60 min. Subsequently, the NiFe foam supported FeNi-LDH was immersed into the mixed solution and transferred into a 100 mL Teflon-lined stainless steel autoclave. After the hydrothermal reaction at 120 °C for 48 h, the  $\text{FeNi}_x\text{Se}$  nanosheet was formed on the surface of the NiFe foam.

### Synthesis of $\text{SeO}_x/\text{FeNi}_x\text{Se}$ heterojunctions

Three-dimensional (3D)  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  nanosheet heterojunctions with interconnected heterostructures were fabricated by the electrodeposition strategy through the HER cycle process in a standard three-electrode system. Typically, a three-electrode system was connected to an electrochemical workstation using Pt foil as the counter electrode, a saturated calomel electrode (SCE) as the reference electrode, NiFe foam supported  $\text{FeNi}_x\text{Se}$  (1 cm × 1 cm) as the working electrode, respectively. The electrodeposition strategy was carried out through the HER cycle process in 1 M KOH. The  $\text{SeO}_x$  films with different thicknesses grown on the surface of  $\text{FeNi}_x\text{Se}$  nanosheets can be obtained by controlling the times of the HER cycle process. The obtained  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  nanosheet heterojunction is named  $\text{CM}_y\text{-FeNi}_x\text{Se}$  ( $y$  represents the HER cycle times). The prepared  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  samples do not need any washing and drying processes, and the OER performance can be tested after electrodeposition directly.

### Characterization

The crystal phase composition of the samples was ascertained by X-ray diffraction (XRD) using Cu  $K\alpha$  radiation with a scan rate of 4°  $\text{min}^{-1}$  from 10° to 80°. Scanning electron microscopy (SEM) and transmission electron microscopy (TEM) coupled



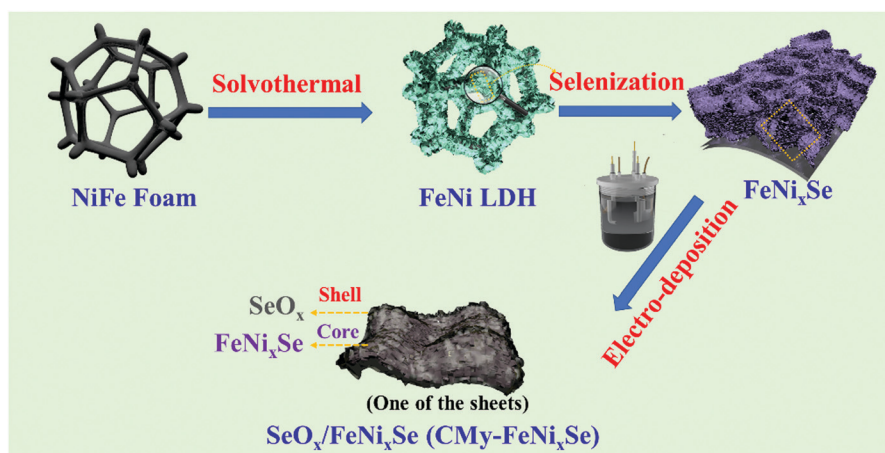
with elemental mapping were used to characterize the morphologies of the products. The micro-nanostructures were recorded using HRTEM. X-ray photoelectron spectroscopy (XPS) was performed on a Kratos Analytical AXIS Supra system. The details of the electrocatalytic measurements and theoretical calculation are shown in the ESI.†

## Results and discussion

### *In situ* growth of $\text{SeO}_x$ films on the surface of Ni–Fe–selenide nanosheets and catalyst characterization

The synthetic route of  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  (named  $\text{CM}_y\text{-FeNi}_x\text{Se}$ ,  $y$  represents HER cycle times) 3D nanosheets with interconnected heterostructures is illustrated in Scheme 1. Specifically, FeNi-LDH was firstly synthesized *via* a facile solvothermal reaction. Then, an *in situ* selenization process was applied to obtain Ni–Fe–selenide ( $\text{FeNi}_x\text{Se}$ ) nanosheets. Finally,  $\text{CM}_y\text{-FeNi}_x\text{Se}$  was successfully fabricated by the electrodeposition strategy through different HER cycle times in a standard three-electrode system. SEM images (Fig. S1a, ESI†) showed that ultra-thin FeNi-LDH with a smooth and flat surface was uniformly distributed on the NiFe foam, and interweaved with each other to form a 3D interconnected network structure. This special architecture was conducive to increasing the number of active sites and facilitating electron transport. The TEM images (Fig. S2, ESI†) further demonstrate the 3D interconnected network-like structure of FeNi-LDH, which is consistent with the SEM results. It is worth noting that there is a porous structure inside the nanosheets (Fig. S2, ESI†), which is conducive to the diffusion of the electrolyte. After selenization, the  $\text{FeNi}_x\text{Se}$  nanosheets maintain their 3D interconnected structure. However, the nanosheets become thicker and coarser, and the secondary structure of the nanosheet is composed of a large number of nanoparticles as shown in Fig. 1a. Elemental mapping (Fig. 1d1), energy dispersive X-ray spectroscopy (EDX) and percentage of elemental weight (Fig. S3, ESI†) show the uniform distribution of Ni, Fe and Se in  $\text{FeNi}_x\text{Se}$  nanosheets, and

the elemental weight ratio is close to 15.8:1:22.1. The slight excess O may come from the absorbed species on its surface. The uniform distribution of Fe proves that in the hydrothermal process, the Fe element corroded from the NiFe foam substrate is successfully doped into the nickel hydroxide nanosheet and the content is very low (the atomic ratio of Ni and Fe is close to 15:1). It has been reported that the electrocatalytic performance of Ni-based materials can be greatly improved by doping the Fe element.<sup>31</sup> TEM images (Fig. 1b1-2) showed that the diameter of most nanoparticles in  $\text{FeNi}_x\text{Se}$  is distributed within 50 nm, and they have clear edges (Fig. 1c1). Such a unique structure of nanosheets composed of nanoparticles can further increase the specific surface area and active sites, and effectively increase the electrolyte contact in electrochemical applications. The HRTEM image clearly proves the presence of NiSe with interlayer distances of 0.30 nm and 0.24 nm, corresponding to the (101) and (220) facets of NiSe, respectively. The corresponding selected area electron diffraction (SAED) pattern (Fig. 1c2) also shows the highly crystalline nature of NiSe and  $\text{Ni}_{0.85}\text{Se}$ , and the NiSe is the major phase. Due to the low content of  $\text{Ni}_{0.85}\text{Se}$ , no crystalline interplanar spacing of  $\text{Ni}_{0.85}\text{Se}$  was detected in the HRTEM image. The SEM images of  $\text{CM}_7\text{-FeNi}_x\text{Se}$  (Fig. 1a3-4) after electrodeposition show no obvious morphological change, however, from the TEM images (Fig. 1b3-4 and c4) we can see that the edge of the particle becomes unclear and thinner, and a mixed thin layer ( $\sim 8$  nm) composed of crystalline and amorphous phases appeared on the surface of the original particles, which is attributed to the  $\text{SeO}_x$  and  $\text{Ni}(\text{OH})_2/\text{NiOOH}$  produced during the HER cycle process,<sup>32</sup> indicating the transformation of the structure starting from the surface to forming the transition metal oxides. According to the HRTEM (Fig. 1c6), the lattice fringes corresponding to the (112) and (202) planes of  $\text{SeO}_2$  are captured, which are generated during the *in situ* electrodeposition process. The SAED patterns after electrodeposition exhibit clear rings rather than the scattered dots and blurry rings, which are due to the multiple small domains (Fig. 1c5). The elemental mapping (Fig. 1d2) shows that the content of O increased significantly after the HER cycle process, and the EDX



Scheme 1 Schematic illustration of the formation process of hierarchical  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  ( $\text{CM}_y\text{-FeNi}_x\text{Se}$ ).





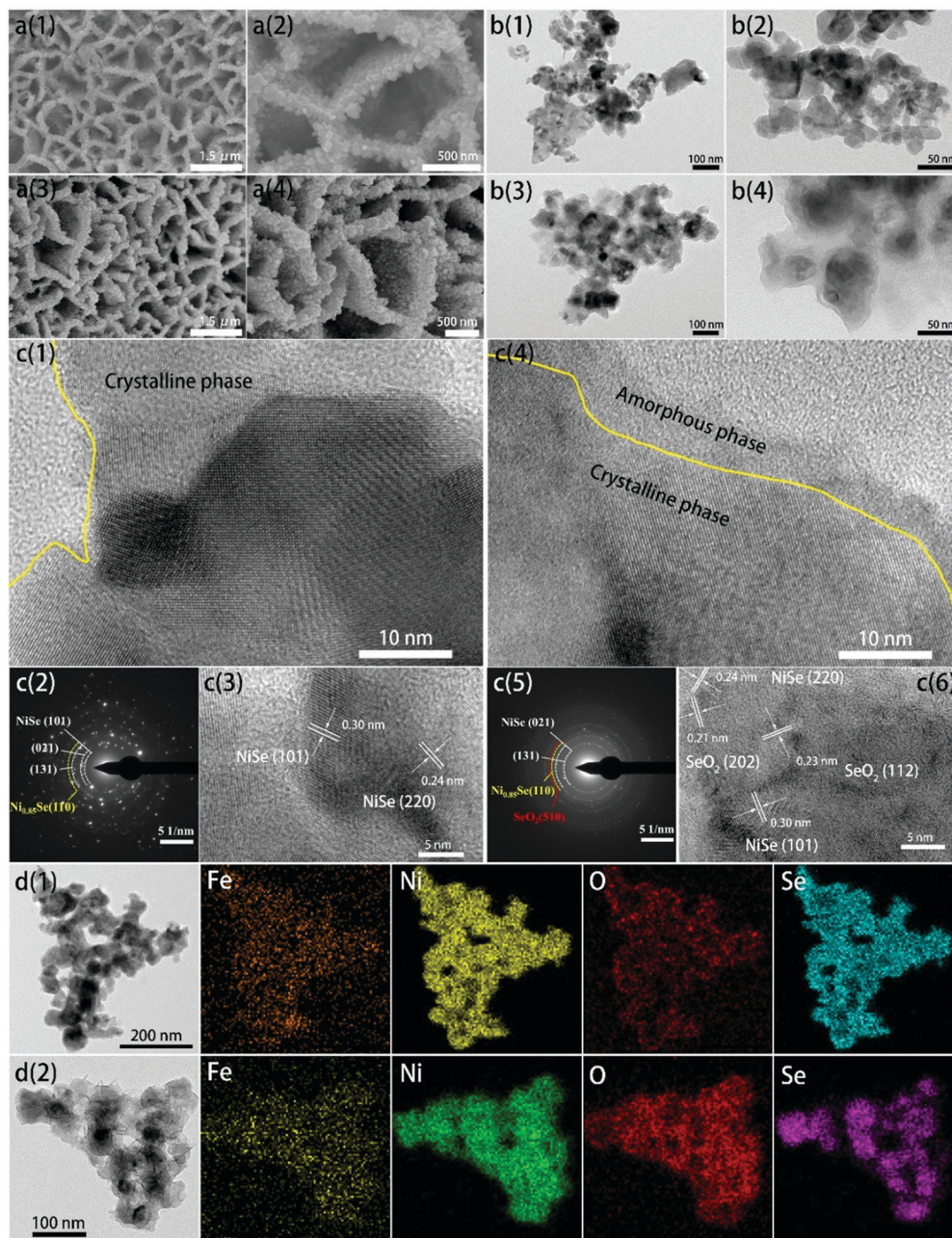


Fig. 1 (a1 and a2) SEM images, (b1 and b2) TEM images, (c1 and c3) HRTEM images, (c2) SAED pattern and (d1) EDX elemental mapping of  $\text{FeNi}_x\text{Se}$ ; (a3 and a4) SEM images, (b3 and b4) TEM images, (c4 and c6) HRTEM images, (c5) SAED pattern and (d2) EDX elemental mapping of CM7- $\text{FeNi}_x\text{Se}$ .

(Fig. S3, ESI<sup>†</sup>) shows that the atomic ratio of O has increased by 24% after the HER, proving that  $\text{SeO}_x$  was indeed generated *in situ* on the surface of  $\text{FeNi}_x\text{Se}$  during the electrodeposition process, which was consistent with the TEM results.

Fig. 2a shows the XRD patterns of NiFe Foam, FeNi LDH,  $\text{FeNi}_x\text{Se}$  and CM7- $\text{FeNi}_x\text{Se}$ . The diffraction peaks of NiFe foam match well with those of the  $\text{FeNi}_3$  alloy (JCPDS no. 38-0419), metallic Ni (JCPDS no. 04-0850) and Fe (JCPDS no. 06-0696). After hydrothermal treatment, the XRD pattern of FeNi LDH shows some new diffraction peaks that appeared at  $2\theta = 11.3^\circ, 22.7^\circ, 33.4^\circ, 34.4^\circ, 38.7^\circ, 45.9^\circ, 59.9^\circ$  and  $61.2^\circ$ , which correspond to

the (003), (006), (101), (012), (015), (018), (110) and (113) planes of  $\text{Ni}(\text{OH})_2$  (PDF 38-0715).<sup>33</sup> No diffraction peaks of Fe-related hydroxide can be detected, which may be due to the low content of Fe element, and this result was confirmed by subsequent elemental quantitative analysis of EDX and XPS. Then, an *in situ* selenization process was applied, and FeNi-LDH was transformed into  $\text{FeNi}_x\text{Se}$  completely with the appearance of a series of new signal peaks corresponding to the selenides. The characteristic diffraction peaks centered at  $2\theta = 31.0^\circ, 34.0^\circ, 36.0^\circ, 38.6^\circ, 46.5^\circ, 48.0^\circ, 53.5^\circ, 55.1^\circ, 56.0^\circ$  and  $62.7^\circ$  in CM7- $\text{FeNi}_x\text{Se}$  could be assigned to the (300), (021), (220), (211), (131),



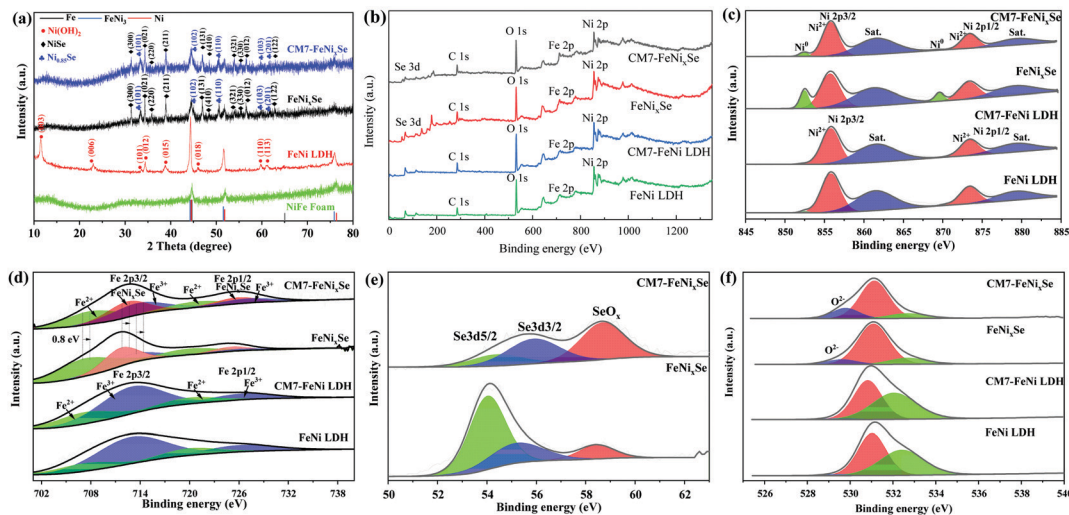


Fig. 2 (a) XRD patterns of NiFe foam, FeNi LDH, CM7-FeNi<sub>x</sub>Se and FeNi<sub>x</sub>Se. (b) XPS survey spectra and high-resolution XPS spectra of (c) Ni 2p, (d) Fe 2p, (e) Se 3d and (f) O 1s of NiFe LDH, CM7-NiFe LDH, CM7-FeNi<sub>x</sub>Se and FeNi<sub>x</sub>Se.

(410), (321), (330), (012) and (122) planes of NiSe (JCPDS no. 18-0887),<sup>34</sup> and the characteristic diffraction peaks at  $2\theta = 33.1^\circ$ ,  $44.9^\circ$ ,  $50.4^\circ$ ,  $60.2^\circ$  and  $61.7^\circ$  can be assigned to the (101), (102), (110), (103) and (201) planes of Ni<sub>0.85</sub>Se (JCPDS no. 18-0888),<sup>35</sup> and both NiSe and Ni<sub>0.85</sub>Se were found for FeNi<sub>x</sub>Se. We also noticed that no significant changes were found in the diffraction peaks after electro-deposition due to the ultrathin structure and low content of the deposited SeO<sub>x</sub> layer (Fig. 2a).

XPS analysis confirms the presence of Ni, Se, Fe, O and C in CM7-FeNi<sub>x</sub>Se and FeNi<sub>x</sub>Se (Fig. 2b). For FeNi<sub>x</sub>Se, the peaks at 852.4 and 870.2 eV belong to metallic Ni 2p from the NiFe foam (Fig. 2c).<sup>36,37</sup> The peaks at binding energies of 855.5 and 873.6 eV with two shakeup satellites (861.0 and 879.4 eV) can be attributed to the Ni 2p<sub>3/2</sub> and Ni 2p<sub>1/2</sub> of Ni<sup>2+</sup>, respectively, which confirm the Ni<sup>2+</sup> state in FeNi<sub>x</sub>Se.<sup>38</sup> After electro-deposition, the peak intensity of metallic Ni is reduced and almost disappears. This is because of the significant oxidation that occurred on the surface of the FeNi<sub>x</sub>Se during the electro-deposition process, and a layer of SeO<sub>x</sub> covered the surface of FeNi<sub>x</sub>Se. Since XPS can only detect the surface state of the samples, the covering of the oxide layer will leave the bottom NiFe foam not easy to be detected. For FeNi LDH, the peak shape of Ni 2p (Fig. 2c) and XRD patterns (Fig. S4b, ESI<sup>†</sup>) before and after the electro-deposition process did not change significantly, proving that there were no significant valence state changes and crystal phase composition changes on the surface of FeNi LDH during the electro-deposition process. This result could also be proved by the EDX analysis (Fig. S2, ESI<sup>†</sup>) that there is a minor increased proportion of oxygen for CM7-FeNi LDH, which may be attributed to the surface hydroxylation/oxidation during the HER cycle process. For the Fe 2p spectrum (Fig. 2d) in FeNi<sub>x</sub>Se, the binding energies at 707.2 and 719.94 eV conform to Fe<sup>2+</sup>, and the peaks at 713.5 eV and 727.2 eV belong to Fe<sup>3+</sup>.<sup>39–41</sup> It is worth noting that new peaks in FeNi<sub>x</sub>Se appear at 711.8 and 725.5 eV, which correspond to FeNi<sub>x</sub>Se, and the absence of satellite peaks of Fe<sup>2+</sup> and Fe<sup>3+</sup> indicates that Fe<sup>2+</sup> and Fe<sup>3+</sup> ions were incorporated into

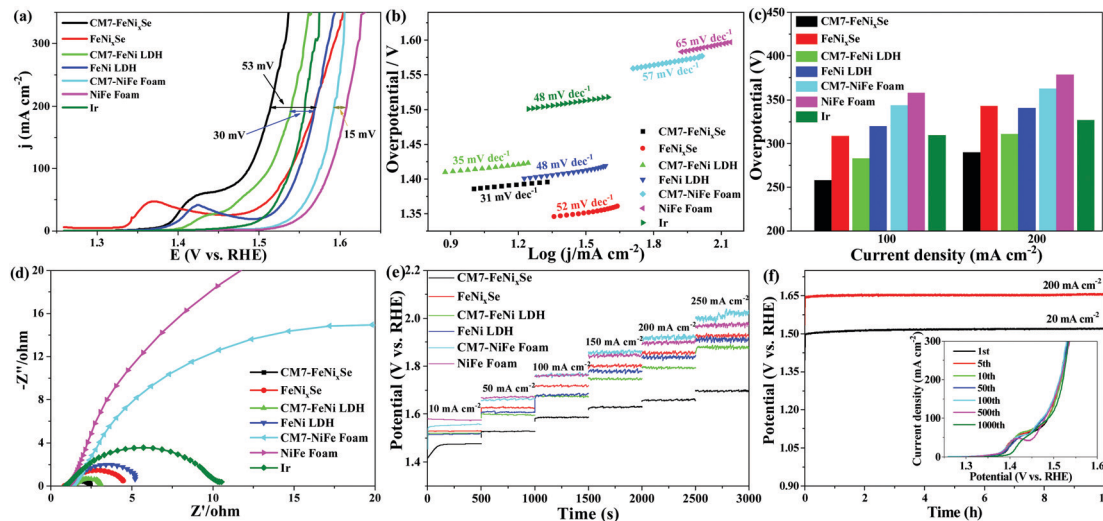
Ni<sub>x</sub>Se.<sup>42</sup> After the electro-deposition process, the binding energies of Fe<sup>2+</sup> and Fe<sup>3+</sup> shift towards higher binding energies, confirming a higher oxidation state of the Fe element.<sup>43</sup> As for the Se 3d spectra of FeNi<sub>x</sub>Se (Fig. 2e), two peaks located at 53.9 and 55.3 eV correspond to Se 3d<sub>5/2</sub> and Se 3d<sub>3/2</sub>, respectively, which shows the presence of metal-selenium bonds of Se<sup>2-</sup>. The small peak at 58.3 eV is associated with trace amounts of SeO<sub>x</sub>, which is caused by the FeNi<sub>x</sub>Se exposure to air.<sup>44,45</sup> After the electro-deposition process, the intensity of the SeO<sub>x</sub> peak is significantly enhanced, while the peaks of Se 3d<sub>5/2</sub> and Se 3d<sub>3/2</sub> decrease and appear at positions with slightly higher binding energies (~0.3 eV), indicating the leaching and oxidation of Se, and the electrons were transferred from FeNi<sub>x</sub>Se to SeO<sub>x</sub>.<sup>46</sup> Combined with the above results, this strongly suggests that there exists a strong electronic coupling between FeNi<sub>x</sub>Se and SeO<sub>x</sub>. It is further demonstrated that SeO<sub>x</sub> is produced on the surface of FeNi<sub>x</sub>Se during the electro-deposition process, which is consistent with the above TEM and SEM results. The phenomenon of the surface oxidation process can also be demonstrated by the increased intensity of the lattice oxygen (O<sup>2-</sup>) peak at 529.9 eV in FeNi<sub>x</sub>Se after the electro-deposition process (CM7-FeNi<sub>x</sub>Se) (Fig. 2f).<sup>47</sup> The increased proportion of lattice oxygen is attributed to the formation of Se-O bonds during the electro-deposition process. For FeNi LDH, the O 1s spectrum showed no obvious change before and after the HER cycle process, although the content of oxygen on the surface increased, which may be due to the increased oxygen from surface hydroxylation/oxidation during the electro-deposition process.

### Oxygen evolution reaction performance and stability assessment

The electrocatalytic OER performance was measured in 1 M KOH. Fig. 3a shows that after electro-deposition of SeO<sub>x</sub>, the resultant CM7-FeNi<sub>x</sub>Se exhibits a great enhancement in OER activity. It exhibits the lowest overpotential ( $\eta_{200}$ ) of only 285 mV to achieve a current density of 200 mA cm<sup>-2</sup>, which is much lower than that of the noble metal Ir ( $\eta_{200} = 326$  mV), a







**Fig. 3** OER performance of NiFe foam, CM7-NiFe foam, FeNi LDH, CM7-FeNi LDH, CM7-FeNi<sub>x</sub>Se, FeNi<sub>x</sub>Se and Ir conducted in 1 M KOH. (a) Polarization curves and (b) the corresponding Tafel plots. (c) Comparison of overpotential values at a current density of 100 mA cm<sup>-2</sup> and 200 mA cm<sup>-2</sup>. (d) Nyquist plots (overpotential = 250 mV). (e) Multi-step chronopotentiometric curve of samples without iR compensation. (f) Chronopotentiometry curves of CM7-FeNi<sub>x</sub>Se at constant current densities of 20 and 200 mA cm<sup>-2</sup> without iR compensation. The inset shows the OER LSV curves of the CM7-FeNi<sub>x</sub>Se catalyst after different CV cycles at a scan rate of 20 mV s<sup>-1</sup> in a 1 M KOH electrolyte.

benchmark catalyst for the OER. The overpotential is reduced by 55 mV compared with that of FeNi<sub>x</sub>Se ( $\eta_{200} = 340$  mV). The small oxidation peak at 1.35–1.45 V can be assigned to the oxidation of Ni<sup>2+</sup> to Ni<sup>3+</sup> or Ni<sup>4+</sup> species.<sup>48,49</sup> The lower OER overpotential suggests the superior OER activity, which is compared favorably to many other recently reported selenide based high-performance OER catalysts (Table S1, ESI†). To demonstrate the role of electro-deposited SeO<sub>x</sub> on OER performance improvement, we also tested the OER performance of FeNi LDH before and after the HER cycle process. It shows that the OER performance of the CM7-FeNi LDH electrode is much worse than that of CM7-FeNi<sub>x</sub>Se, but the  $\eta_{200}$  of CM7-FeNi LDH ( $\eta_{200} = 310$  mV) is also reduced by about 30 mV compared with that of FeNi LDH ( $\eta_{200} = 340$  mV), which is attributed to the increased active sites obtained from surface hydroxylation/oxidation during the electro-deposition process. In contrast, the CM7-NiFe foam exhibits similar activity ( $\eta_{200} = 364$  mV) to the NiFe foam ( $\eta_{200} = 379$  mV), which proves that the HER cycle process has no significant influence on the electrocatalytic activity of NiFe foam. It also indirectly proves that the surface state of NiFe foam is relatively stable, and the HER cycle process does not cause the phase change of the surface composition of NiFe foam, which can be further confirmed by the invariant crystal phase composition in the XRD patterns before and after the HER cycle process (Fig. S4a, ESI†). This result proves that the introduction of both SeO<sub>x</sub> and surface hydroxylation/oxidation can effectively enhance the OER electrocatalytic activity of the materials, but the promotion effect of the former is even more obvious. Thus, it can be inferred that the SeO<sub>x</sub> formed on the FeNi<sub>x</sub>Se surface during the electro-deposition process is the real active center.

The Tafel plots are investigated to reveal the electrocatalytic kinetics for the OER. As can be seen in Fig. 3b, CM7-FeNi<sub>x</sub>Se

possesses a lower Tafel value of 31 mV dec<sup>-1</sup>, which is much smaller than those of FeNi<sub>x</sub>Se (52 mV dec<sup>-1</sup>), FeNi LDH (48 mV dec<sup>-1</sup>), CM7-FeNi LDH (35 mV dec<sup>-1</sup>), NiFe foam (65 mV dec<sup>-1</sup>), CM7-NiFe foam (57 mV dec<sup>-1</sup>), and commercial Ir (48 mV dec<sup>-1</sup>), suggesting the enhanced OER reaction kinetics with the formation of the SeO<sub>x</sub> layer. For a further clear comparison of these catalysts, the overpotentials with current densities of 100 and 200 mA cm<sup>-2</sup> are plotted and shown in Fig. 3c. The CM7-FeNi<sub>x</sub>Se electrode required overpotentials of 258 mV and 285 mV, respectively, which were much lower than other catalysts. Electrochemical impedance spectroscopy (EIS, Fig. 3d) in the frequency range of 0.01–100 kHz was performed to investigate the OER kinetics of these catalysts. As shown in Fig. 3d, after the electrodeposition process, the electron transfer rate of CM7-FeNi<sub>x</sub>Se becomes faster, which proves that a small amount of the SeO<sub>x</sub> layer on the surface can provide more electrochemically active sites, which is beneficial for the OER reaction. The result can also be proved by subsequent characterization of the electrochemically active surface areas (ECSAs) of the samples. As shown in Fig. S5 and S6 (ESI†), the electrochemical double-layer capacitances ( $C_{dl}$ s) of these samples were measured by the CV method and the corresponding ECSAs were calculated to evaluate the OER activity. Fig. S5 (ESI†) presents the CV results of CM7-FeNi<sub>x</sub>Se, FeNi<sub>x</sub>Se, FeNi LDH, CM7-FeNi LDH, pure NiFe foam, and CM7-NiFe foam at different current scan rates. The calculated  $C_{dl}$  values, shown in Fig. S6 (ESI†), for CM7-FeNi<sub>x</sub>Se, FeNi<sub>x</sub>Se, CM7-FeNi LDH, FeNi LDH, CM7-NiFe foam, and NiFe foam are 26.7, 17.1, 4.76, 3.32, 2.35 and 1.42 mF cm<sup>-2</sup>, respectively. The ECSAs of the CM7-FeNi<sub>x</sub>Se, FeNi<sub>x</sub>Se, CM7-FeNi LDH, FeNi LDH, CM7-NiFe foam, and NiFe foam were calculated to be 667.7, 427.5, 119.0, 83.0, 58.7 and 35.3 cm<sup>2</sup>, respectively. The result indicates that CM7-FeNi<sub>x</sub>Se has a much higher ECSA than other samples, and the increased



ECSA could increase the reaction sites, hence, more catalytic reactions would occur on the surface, which makes a considerable contribution to its higher OER catalytic activity. The catalytic stability and durability of these electrodes for the OER were also evaluated by multi-step chronopotentiometric tests with the current increasing from 10 to 250 mA cm<sup>-2</sup> (Fig. 3e). It can be seen that the potential remains stable in each current density range for all the electrodes, confirming the prominent stability of these samples. Among them, CM7-FeNi<sub>x</sub>Se has the lowest overpotential, which indicated its remarkable conductivity and rapid mass transfer capability for the OER. Furthermore, the long-term stability of the CM7-FeNi<sub>x</sub>Se electrode was evaluated by the chronopotentiometric measurement at a current density of 20 and 200 mA cm<sup>-2</sup>. The chronopotentiometric curves in Fig. 3f show that the potential remained stable over a period of 10 h. Moreover, the inset in Fig. 3f proves that the LSV polarization curves of CM7-FeNi<sub>x</sub>Se after 1000 CV cycles showed negligible changes, further demonstrating the excellent electrocatalytic stability of CM7-FeNi<sub>x</sub>Se for the OER.

In order to confirm the stability of CM7-FeNi<sub>x</sub>Se in alkaline solution for the OER, we further characterized the structure and morphology of CM7-FeNi<sub>x</sub>Se after a long-term stability test at a current density of 20 mA cm<sup>-2</sup> for 10 h. SEM and TEM images show that CM7-FeNi<sub>x</sub>Se after the chronopotentiometry test (CD-CM7-FeNi<sub>x</sub>Se) retains the uniform nanosheet structure (Fig. 4a and b), no obvious morphological change after a long-term stability test, the mixed thin layer composed of crystalline and amorphous phases on the surface remains intact, and the thickness has not changed much (Fig. 4c). Both the XRD pattern and HRTEM image of CD-CM7-FeNi<sub>x</sub>Se are almost the same as those of CM7-FeNi<sub>x</sub>Se. A slight change is that the peak strength of NiSe and Ni<sub>0.85</sub>Se decreased, which is

due to the hydrated oxides and (oxy)hydroxides generated on the surface of CD-CM7-FeNi<sub>x</sub>Se. Elemental mapping (Fig. 4f) shows that after a long period of testing, each element is still evenly distributed on the surface of the nanosheet. This result was confirmed by subsequent elemental quantitative analysis of EDX (Fig. S7, ESI†). Previous reports have shown that in the OER test, the Se inside the selenides will gradually dissolve in the electrolyte during the test, resulting in the decomposition of the electrode materials.<sup>27,28,50</sup> However, according to the above characterization, we found that pre-covering with a thin SeO<sub>x</sub> layer on the surface of FeNi<sub>x</sub>Se can significantly improve the stability of the selenide materials. In the subsequent OER tests, the oxide layer can prevent the internal Se from dissolution, thus showing excellent structural stability and long cycle life. The corresponding high-resolution XPS spectra of CM7-FeNi<sub>x</sub>Se and CD-CM7-FeNi<sub>x</sub>Se also proved the stability of the materials, as shown in Fig. S8 (ESI†), except for the characteristic peak at 532.7 eV, which shows that the adsorbed oxygen species (Fig. S8d, ESI†) has been strengthened, due to the adsorption of water molecules from the alkaline solution on the surface after a long period of testing.<sup>51</sup> The other characteristic peaks have not changed from those before the tests. The results further demonstrated that the thin oxide layer deposited on the surface can prevent the internal selenide from directly coming into contact with the electrolyte, thus preventing the loss of Se and maintaining a stable surface state in the OER test.

#### The role of the SeO<sub>x</sub> film thickness

In order to understand the influence of different electro-deposition times on the performance of CM<sub>y</sub>-FeNi<sub>x</sub>Se, the HER and OER LSV curves and EIS spectra at different electro-deposition times were characterized. As shown in Fig. S9a

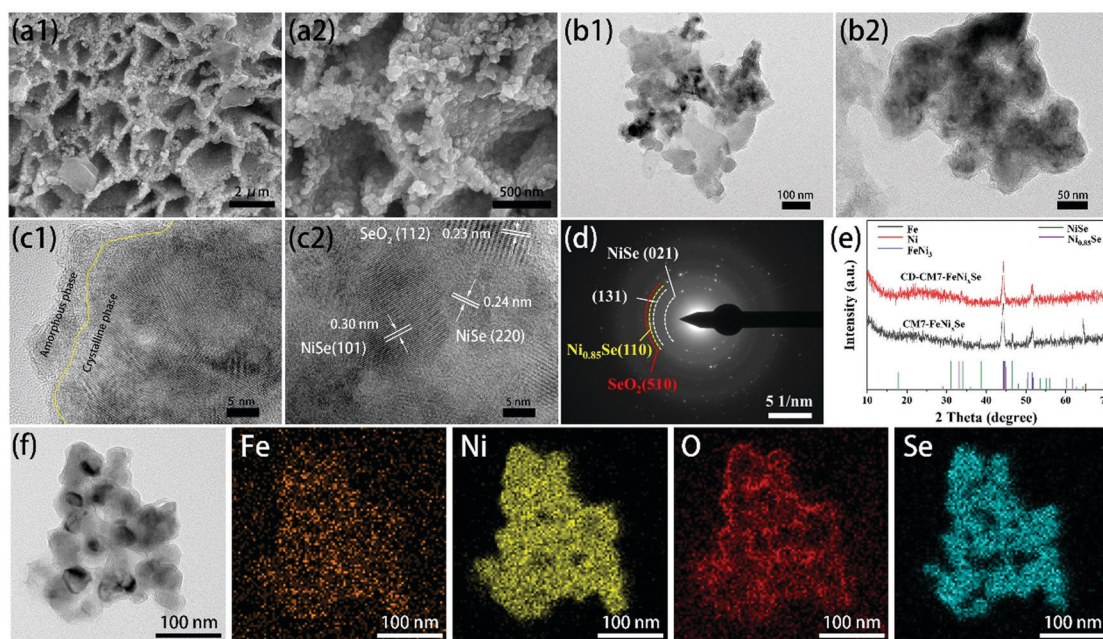
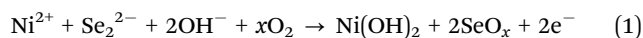


Fig. 4 (a1 and a2) SEM images, (b1 and b2) TEM images, (c1 and c2) HRTEM images, (d) SAED patterns, (e) XRD pattern and (f) EDX elemental mapping of CM7-FeNi<sub>x</sub>Se after the chronopotentiometry test (CD-CM7-FeNi<sub>x</sub>Se) at constant current densities of 20 mA cm<sup>-2</sup> for 10 h.



(ESI<sup>†</sup>), an obvious cathode peak at  $\sim -0.13$  V (vs. RHE) is observed for CM<sub>y</sub>-FeNi<sub>x</sub>Se, which may be assigned to the leaching and subsequent oxidation of Se from FeNi<sub>x</sub>Se to selenium oxide, which has been reported in the previous literature.<sup>32</sup> Lau *et al.* found that both the HER and OER processes of selenides in alkaline solution were accompanied by surface oxidation, and the oxidation degree and phase transition rate during the OER is much stronger and faster, while the oxidation rate during the HER was relatively slow.<sup>32</sup> They show that in the initial reaction stage of the HER, the outermost layer of selenides (NiSe<sub>2</sub>) will ionize in strong KOH solution, and the Se<sub>2</sub><sup>2-</sup> will leach out and combine with the dissolved oxygen to generate SeO<sub>x</sub>, accompanied by the generation of Ni(OH)<sub>2</sub>/NiOOH.<sup>52</sup> The specific mechanism is shown as follows:<sup>32</sup>



We can see that no obvious peak is observed in the first HER, which manifests that there is no obvious decomposition of FeNi<sub>x</sub>Se at this time. With an increase of HER cycle times, the cathode oxidation peak became more and more obvious, which proved that the material had a violent oxidation reaction with the increase of HER cycle times. Until the seventh HER cycle, the curve tends to be stable with little change, indicating that the generated SeO<sub>x</sub> layer on the surface of FeNi<sub>x</sub>Se has become stable, which can prevent the further decomposition of the internal selenide. The corresponding OER performances with different HER cycle times are displayed in Fig. S9c (ESI<sup>†</sup>). It shows that the OER activity of CM<sub>y</sub>-FeNi<sub>x</sub>Se is enhanced with the increase of HER cycle times and tends to stabilise until the seventh cycle. It is proved that the SeO<sub>x</sub> layer has become stable after seven HER cycles, and the thickness of the SeO<sub>x</sub> layer is appropriate, which can improve the OER activity of FeNi<sub>x</sub>Se while inhibiting the decomposition of the internal selenide. The OER kinetics with different HER cycle times were further analyzed by EIS (Fig. S9b, ESI<sup>†</sup>). The charge transfer resistance of CM<sub>y</sub>-FeNi<sub>x</sub>Se gradually reduced with the increase of HER cycle times and tended to be stable after the seventh HER cycle. The surface SeO<sub>x</sub> layer brings more active sites for electrochemical reactions, we propose that the superior OER kinetics may be due to the synergistic effect between the core selenides and surface *in situ* generated SeO<sub>x</sub> layer.

According to previous reports, the oxides formed on the surface at the beginning stage of electrocatalysis are proposed to be the real active centers of OER catalysts.<sup>27,30</sup> However, excessive oxides usually lead to poor electrical conductivity and high charge transfer resistance of the catalysts, which is not conducive to the enhancement of the electrocatalytic performance. In order to investigate the influence of electro-deposition times on the thickness of the oxide layer formed, we selected CM1-FeNi<sub>x</sub>Se, CM7-FeNi<sub>x</sub>Se and CM20-FeNi<sub>x</sub>Se to expound the structure and composition change. Both the SEM and TEM images (Fig. S10a1-c1 and a2-c2, ESI<sup>†</sup>) show no obvious morphological change of FeNi<sub>x</sub>Se after HER cycling, and it still maintains a three-

dimensional nanosheet structure. The high-resolution TEM image indicates that after one HER cycle process, for CM1-FeNi<sub>x</sub>Se, there is no obvious oxide layer formed on the surface of FeNi<sub>x</sub>Se, and only a thin amorphous oxide layer can be observed in the local area (Fig. S10a3, ESI<sup>†</sup>). Although we have found the corresponding interplanar spacing of SeO<sub>2</sub> (Fig. S10a4, ESI<sup>†</sup>), the diffraction ring of SeO<sub>2</sub> was not observed in SAED, due to the low content of SeO<sub>2</sub> in CM1-FeNi<sub>x</sub>Se. This result can be confirmed by EDX results (Fig. S10d, ESI<sup>†</sup>) that the O content of CM1-FeNi<sub>x</sub>Se increased slightly compared with FeNi<sub>x</sub>Se. After 7 HER cycles, the surface of FeNi<sub>x</sub>Se was obviously coated with a thin layer of SeO<sub>2</sub>. Two new (112) and (202) reflections of SeO<sub>2</sub> are captured in Fig. S10b4 (ESI<sup>†</sup>), which are consistent with the SAED results (Fig. S10b5, ESI<sup>†</sup>). Additionally, it can be clearly seen from EDX patterns (Fig. S10d and e, ESI<sup>†</sup>) that the content of O increases from 12.6 to 22.6 wt% upon increasing the HER cycle times. However, with a continuous increase of the HER cycle times, we found that the thickness of the surface oxide layer did not change obviously. According to the EDX results, the O content only increased from 22.6 to 22.9 wt% after 7 to 20 cycles. These results prove that the oxide layer after 7 HER cycles has stabilized, which could prevent the internal selenide from being decomposed continuously during the HER cycle process, and no more new oxides are produced. We noticed that no significant changes were found in the XRD diffraction peaks after different HER cycle times (Fig. S10e, ESI<sup>†</sup>), which may be due to the oxide layer deposited being very thin and the content being very low, and the SeO<sub>x</sub> deposited under HER cycles presents a mixed structure of crystalline and amorphous phases.

In order to investigate the elemental composition and surface chemical states, the XPS technique was employed to explain the structure and composition change of FeNi<sub>x</sub>Se after different HER cycle times. As we can see from Fig. S11a (ESI<sup>†</sup>), with the increase of HER cycle times, the peak intensity of metallic Ni (852.4 and 870.2 eV) is reduced and almost disappears, which is probably due to the covering of the oxide layer leaving the bottom NiFe foam not easy to be detected.<sup>53,54</sup> Compared with the Fe 2p spectrum (Fig. S11b, ESI<sup>†</sup>) of CM1-FeNi<sub>x</sub>Se, a shift to a higher binding energy was observed in the sample of CM7-FeNi<sub>x</sub>Se, indicating a higher oxidation state of the Fe element with an increase of HER cycle times.<sup>43</sup> However, CM7-FeNi<sub>x</sub>Se and CM20-FeNi<sub>x</sub>Se showed similar spectra, indicating that the surface state tends to be stable after 7 HER cycles. As for the Se 3d spectra (Fig. S11c, ESI<sup>†</sup>), the intensity of the SeO<sub>x</sub> peak (58.3 eV) is significantly enhanced from CM1-FeNi<sub>x</sub>Se to CM7-FeNi<sub>x</sub>Se, and the peaks of Se 3d<sub>3/2</sub> and Se 3d<sub>5/2</sub> are decreased and appear at positions with slightly higher binding energies ( $\sim 0.3$  eV), indicating the leaching and oxidation of Se in the FeNi<sub>x</sub>Se with increased HER cycle times.<sup>46</sup> It further demonstrated that SeO<sub>x</sub> is produced on the surface of FeNi<sub>x</sub>Se during the HER cycle process. The increased intensity of the lattice oxygen (O<sup>2-</sup>) peak at 529.9 eV in CM7-FeNi<sub>x</sub>Se also demonstrate the existence of SeO<sub>x</sub> (Fig. S11d, ESI<sup>†</sup>).<sup>55</sup> The above results prove that the outermost layer of NiSe will ionize in strong KOH solution during the HER cycle process, and the Se<sub>2</sub><sup>2-</sup> will leach out and combine with the dissolved oxygen to form a SeO<sub>x</sub> covering on the original selenide surface. With the





increase of HER cycle times, the oxide layer gradually becomes thicker until the seventh HER cycle. After 7 HER cycles, the oxide layer tends to be stable, and the internal selenide is completely covered by the surface oxide layer and is no longer in contact with the KOH solution. Thus, subsequent decomposition will not continue with the further increase of HER cycle times, showing excellent structural stability.

### Understanding the high electrocatalytic activity of the $\text{SeO}_x/\text{FeNi}_x\text{Se}$ heterojunction nanosheets with DFT simulations

As demonstrated by the above results,  $\text{SeO}_x/\text{FeNi}_x\text{Se}$  exhibits rapid charge transfer capability and high performance and structural stability for the OER. This is mainly due to the thin layer of  $\text{SeO}_x$  electrodeposited on the surface of  $\text{FeNi}_x\text{Se}$  by performing the HER cycle that built the 3D interconnected heterojunction between the  $\text{SeO}_x$  layer and  $\text{FeNi}_x\text{Se}$ . Therefore, in order to further understand that the formed heterojunction between the  $\text{SeO}_x$  layer and  $\text{FeNi}_x\text{Se}$  will reduce the surface charge transfer resistance and increase the catalytic activity of  $\text{SeO}_x/\text{FeNi}_x\text{Se}$ , we used density functional theory (DFT) calculations to deeply reveal the mechanism behind the OER process. The optimized geometry models of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  (Fig. 5a) were used to model  $\text{FeNi}_x\text{Se}$  before and after the HER cycle. The projected density of states (DOSs) of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  cross over the Fermi level (Fig. 5b), indicating that both materials show metallic properties.<sup>56</sup> In other words, the  $\text{SeO}_2$  layer with an appropriate thickness grows on the surface of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$ , which will not change the metallic properties of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$ . In contrast, the ultrathin  $\text{SeO}_x$  layer on the surface can facilitate the adsorption of intermediates onto  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and prevent the decomposition of the internal  $\text{FeNi}_x\text{Se}$ , thus improving the structural stability of the electrode. In an alkaline electrolyte, the

OER proceeds by the adsorption and desorption of a series of  $^*\text{OH}$ ,  $^*\text{O}$  and  $^*\text{OOH}$  intermediates formed in the four primary reaction steps with 4 electron transfer (step I:  $\text{OH}^- \rightarrow ^*\text{OH} + \text{e}^-$ ; step II:  $^*\text{OH} + \text{OH}^- \rightarrow ^*\text{O} + \text{H}_2\text{O} + \text{e}^-$ ; step III:  $^*\text{O} + \text{OH}^- \rightarrow ^*\text{OOH} + \text{e}^-$ ; step IV:  $^*\text{OOH} + \text{OH}^- \rightarrow \text{O}_2(\text{g}) + \text{H}_2\text{O} + \text{e}^-$ ), eventually producing  $\text{O}_2$  molecules.<sup>57</sup> The free energy change ( $\Delta G$ ) values for the four primary steps of the OER in  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  are  $-1.28$ ,  $0.52$ ,  $2.73$  and  $2.95$  eV, respectively (Fig. 5c). Specifically, the first step is exothermic, and the next three steps are endergonic. The step required to absorb most energy to proceed can be considered the rate-determining step (RDS) for the entire OER. It is clear that step IV ( $^*\text{OOH} + \text{OH}^- \rightarrow \text{O}_2(\text{g}) + \text{H}_2\text{O} + \text{e}^-$ ) requires the highest free energy change (2.95 eV) for  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$ , indicating that the rate-limiting step is the dehydrogenation of adsorbed  $^*\text{OOH}$ . However, for  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$ , the growth of selenium oxide on the catalyst surface changes the surface electronic structure of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and reduces the adsorption energies of the reaction intermediates. The free energy change ( $\Delta G$ ) values for the four primary steps of the OER in  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  were reduced to more favorable values of  $-0.71$ ,  $0.36$ ,  $2.77$  and  $2.5$  eV, respectively (Fig. 5c). It can be found that the RDS for  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  changes to step III ( $^*\text{O} + \text{OH}^- \rightarrow ^*\text{OOH} + \text{e}^-$ ). That is, the RDS in this case (2.77 eV) is the hydrogenation of adsorbed  $^*\text{O}$ , which is significantly smaller than that of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  (2.95 eV). The  $U_L(\text{OER})$  value can be calculated using the equation,  $U_L(\text{OER}) = \text{Max}_i(\Delta G_i)/ne - 1.23$  eV. The smaller the  $U_L(\text{OER})$  value, the higher the OER catalytic activity. In particular, the  $U_L(\text{OER})$  value for  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  was calculated to be 1.54 V, which is smaller than that of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  ( $U_L = 1.72$  V). This indicates that  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  has higher catalytic activity than  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$ . Therefore, DFT calculation is in good agreement with the experimental results, highlighting the synergetic coupling between  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and  $\text{SeO}_x$  in producing a favorable surface



Fig. 5 Theoretical calculations of  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}$  and  $\text{Ni}_{1-x}\text{Fe}_x\text{Se}@/\text{SeO}_2$  electrocatalysts. (a) Crystal structures, (b) calculated DOS, (c) free energy diagram for the OER over four optimized adsorption geometry of  $\text{O}_2$ ,  $^*\text{OOH}$ ,  $^*\text{O}$ , and  $^*\text{OH}$ .





Fig. 6 (a) Polarization curves for overall water splitting. (b) Amounts of gas experimentally measured and theoretically calculated vs. time for the electrolyzer Pt/C||CM7-FeNi<sub>x</sub>Se at 10 mA cm<sup>-2</sup>. (c) Chronopotentiometry curves tested at constant current densities of 10, 50 and 100 mA cm<sup>-2</sup>.

electronic environment and thereby boosting the OER performance.

### Overall water splitting application

Finally, to further evaluate the practical application of CM7-FeNi<sub>x</sub>Se as high efficiency electrochemical catalysts, an electrolyzer was made with a two-electrode configuration using CM7-FeNi<sub>x</sub>Se as the anode and commercial Pt/C as the cathode for overall water splitting in 1.0 M KOH. For comparison, electrolyzer systems using Pt/C||CM7-FeNi LDH, Pt/C||CM7-NiFe foam and Pt/C||Ir were also tested. It can be seen that the electrolyzer Pt/C||CM7-FeNi<sub>x</sub>Se needs a cell voltage of 1.637 V to achieve a current density of 50 mA cm<sup>-2</sup> (Fig. 6a), which is much lower than that of the other electrolyzer systems at the same current density (Pt/C||CM7-FeNi LDH: 1.672 V; Pt/C||CM7-NiFe Foam: 1.767 V; Pt/C||Ir: 1.667 V). The performance is also superior to most previously reported selenide catalysts as shown in Table S2 (ESI<sup>†</sup>). Attractively, Pt/C||CM7-FeNi<sub>x</sub>Se presents a faradaic efficiency close to 99% for the OER (Fig. 6b). Furthermore, to evaluate the system stability of overall water splitting, multi-step chronopotentiometric tests (Fig. 6c) were conducted with the current density increasing from 20 mA cm<sup>-2</sup> to 100 mA cm<sup>-2</sup>. The CM7-FeNi<sub>x</sub>Se based electrolyzer system exhibited the most beneficial electrocatalytic activity at different current densities, and upon increasing the current density, the corresponding potential increases and

remains stable, which shows the excellent cycling stability of the CM7-FeNi<sub>x</sub>Se electrode.

### Conclusions

In summary, a rapid, facile, green and controllable electro-deposition method was developed to synthesize three-dimensional (3D) SeO<sub>x</sub>/FeNi<sub>x</sub>Se heterojunction nanosheets with interconnected heterostructures through the hydrogen evolution reaction (HER) cycle process. It only takes 90 s for one time electrodeposition, and a stable SeO<sub>x</sub> layer with optimum thickness can be formed on the surface of FeNi<sub>x</sub>Se after seven electrodeposition cycles. Detailed spectroscopic and DFT investigations disclose that the *in situ* electrodeposited ultrathin SeO<sub>x</sub> layer could significantly modify the surface electronic structure and provide high electrochemical surface areas and rich active sites, and the electrocatalytic activity of FeNi<sub>x</sub>Se was significantly improved by the synergistic effect between FeNi<sub>x</sub>Se and the SeO<sub>x</sub> layer. Moreover, the strong electron interaction between FeNi<sub>x</sub>Se and SeO<sub>x</sub> could reduce the surface charge transfer resistance and speed up the catalytic reaction kinetics in the electrocatalytic reaction. The ultrathin SeO<sub>x</sub> layer on the surface can prevent the decomposition of the internal FeNi<sub>x</sub>Se and thus improve the structural stability of the electrode. The optimized SeO<sub>x</sub>/FeNi<sub>x</sub>Se (CM7-FeNi<sub>x</sub>Se) electrode shows excellent OER performance with a current density of 200 mA cm<sup>-2</sup>



occurring at a small overpotential of 285 mV in 1.0 M KOH. This study offers a new strategy for the construction of a metal selenide heterojunction protected by an ultra-thin selenium oxide coating.

## Conflicts of interest

There are no conflicts to declare.

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